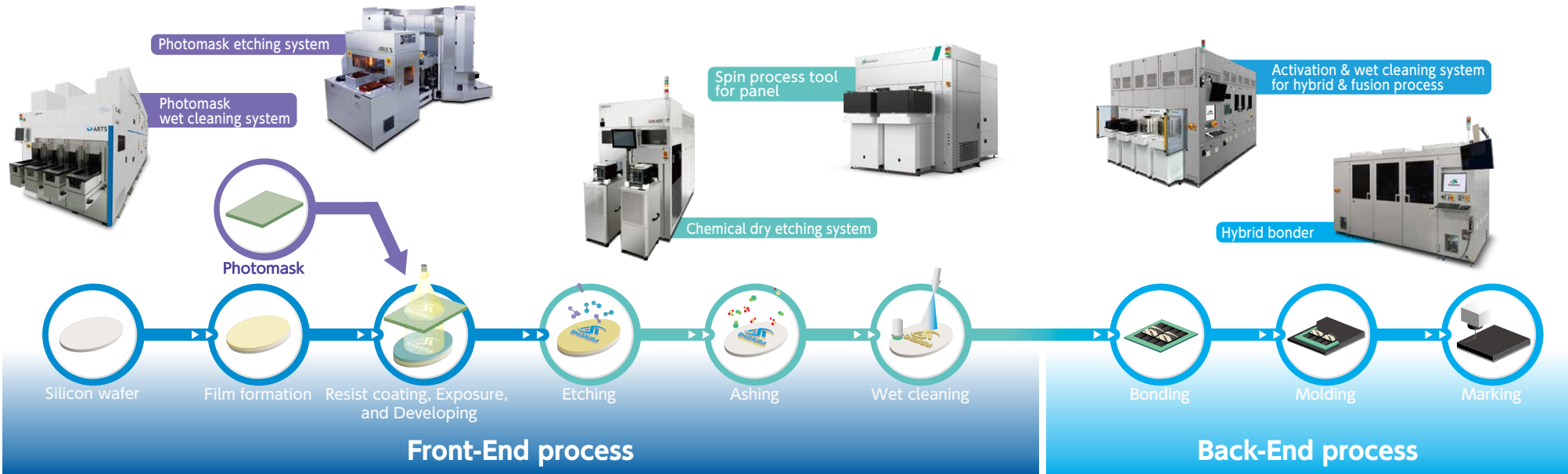


Process diagram

Photomask process

We provide a range of etching system and wet cleaning system that facilitate defect-free photomask manufacturing.



Wafer process

We offer a range of single-wafer cleaning system that achieves high levels of cleanliness and supports various processes.

Device process

Our lineup includes etching system and ashing system that contribute to device reliability and improved yields.

Bonding process

We offer a range of high accuracy bonders that support various kinds of processes and packages.

*The equipment shown in the process diagram represents the main equipment used in each process.